



# Working @ CERN

**"Developing a fast simulator for  
irradiated silicon detectors"**  
(TRACS radiation upgrade)

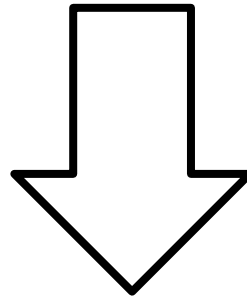


11 - August - 2015

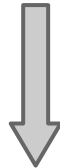
Álvaro Díez González-Pardo  
(Summer Student 2015)

# Project description

*“Simulation and measurements of heavily irradiated silicon detectors: CMS HPK and HGC campaigns”*



Expand TRACS functionality and performance



**TRACS** is an open source program developed by Pablo de Castro (Summer Student 2014)  
Fast **TR**Ansist **C**urrent **S**imulator based on Ramo's theorem that uses external libraries for calculations FEM

# Project description

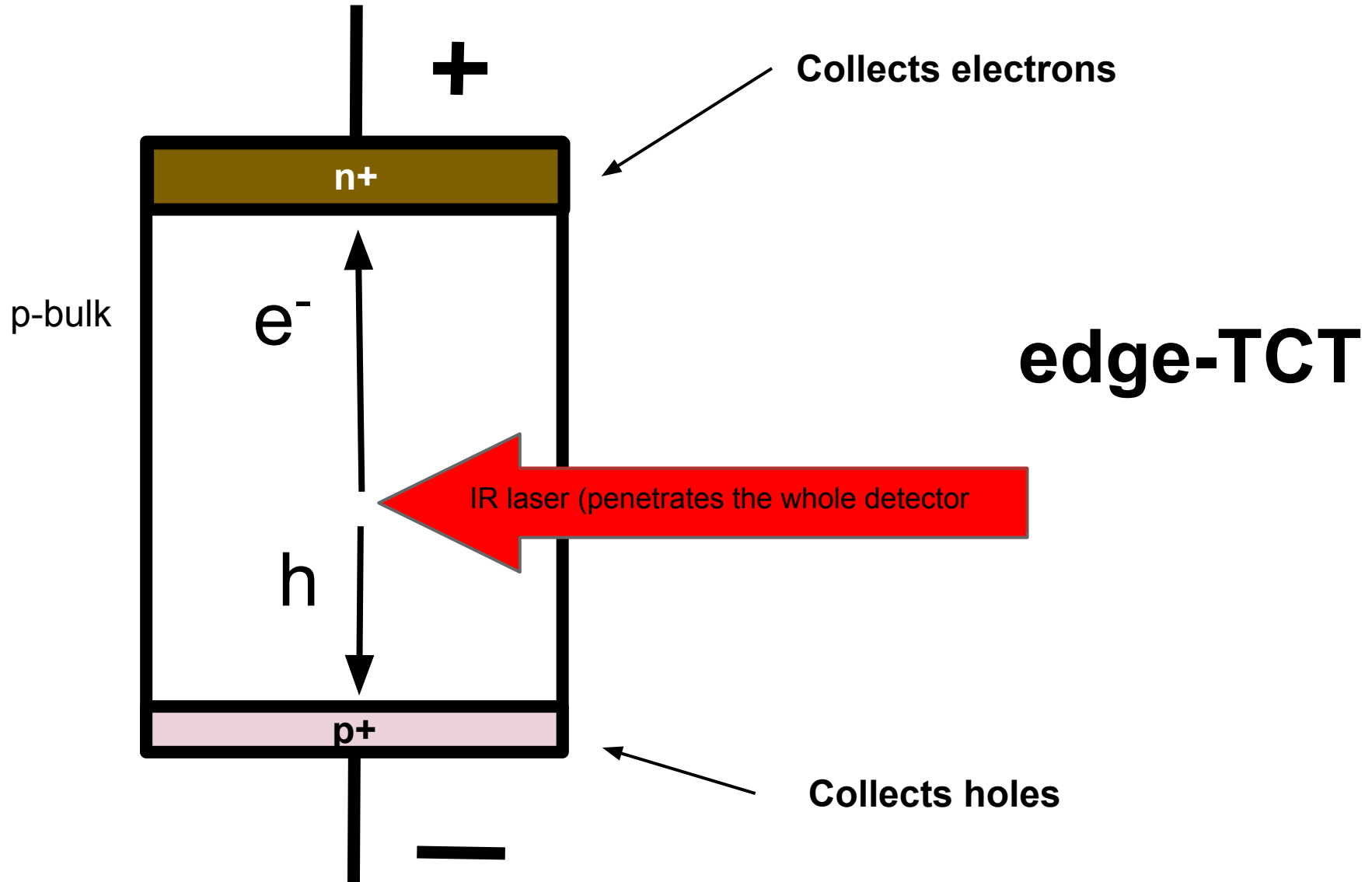
## What we want to achieve:

*“Fast simulation of irradiated detectors with selectable free parameters that can be fitted to measurements”*

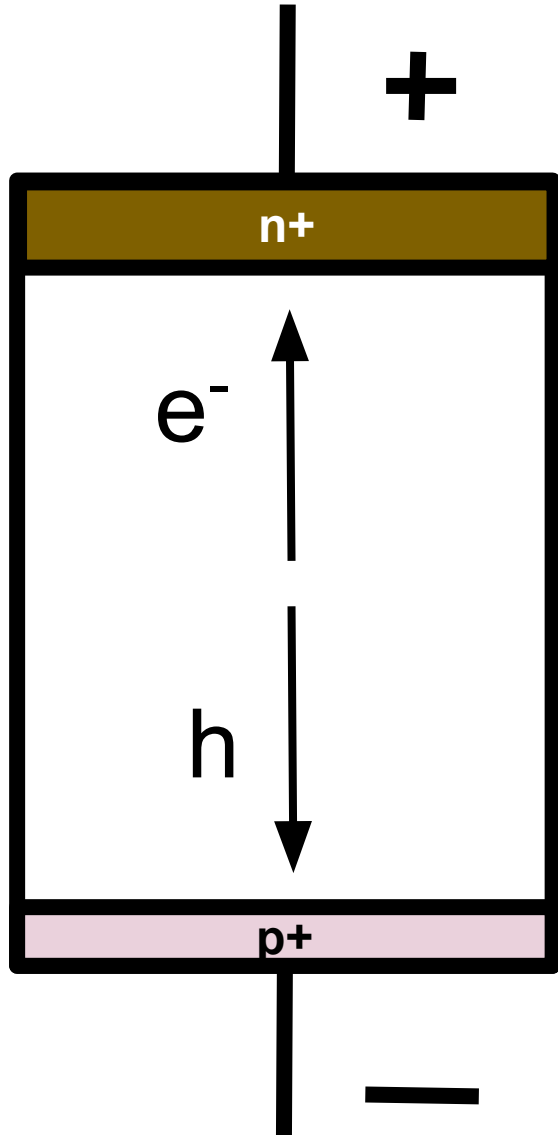
## What we need to implement in TRACS

- Simulation of irradiated detectors
- Tunable Neff distribution  $\longrightarrow$  Our free parameters
- Simulate trapping effects
- Accurate simulation of electronics (Shaping)
- Performance improvements (parallelization?)

# Basics of silicon detectors



# Basics of silicon detectors



Velocity is proportional to the electric field



Current generated due to electric induction

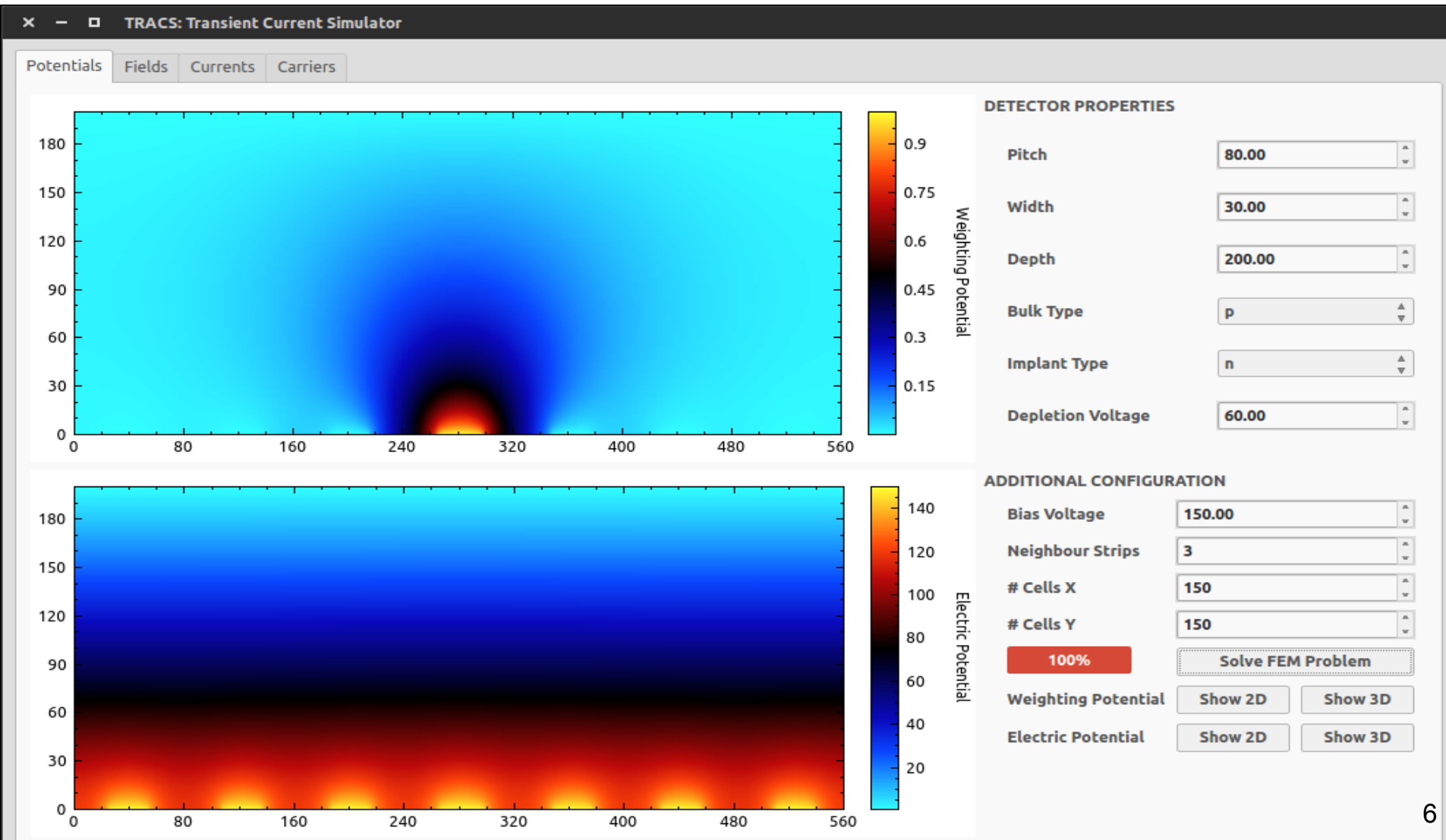
i.e. its proportional to the velocity



**edge-TCT illumination  
allows as to “see” the  
field inside the detector**

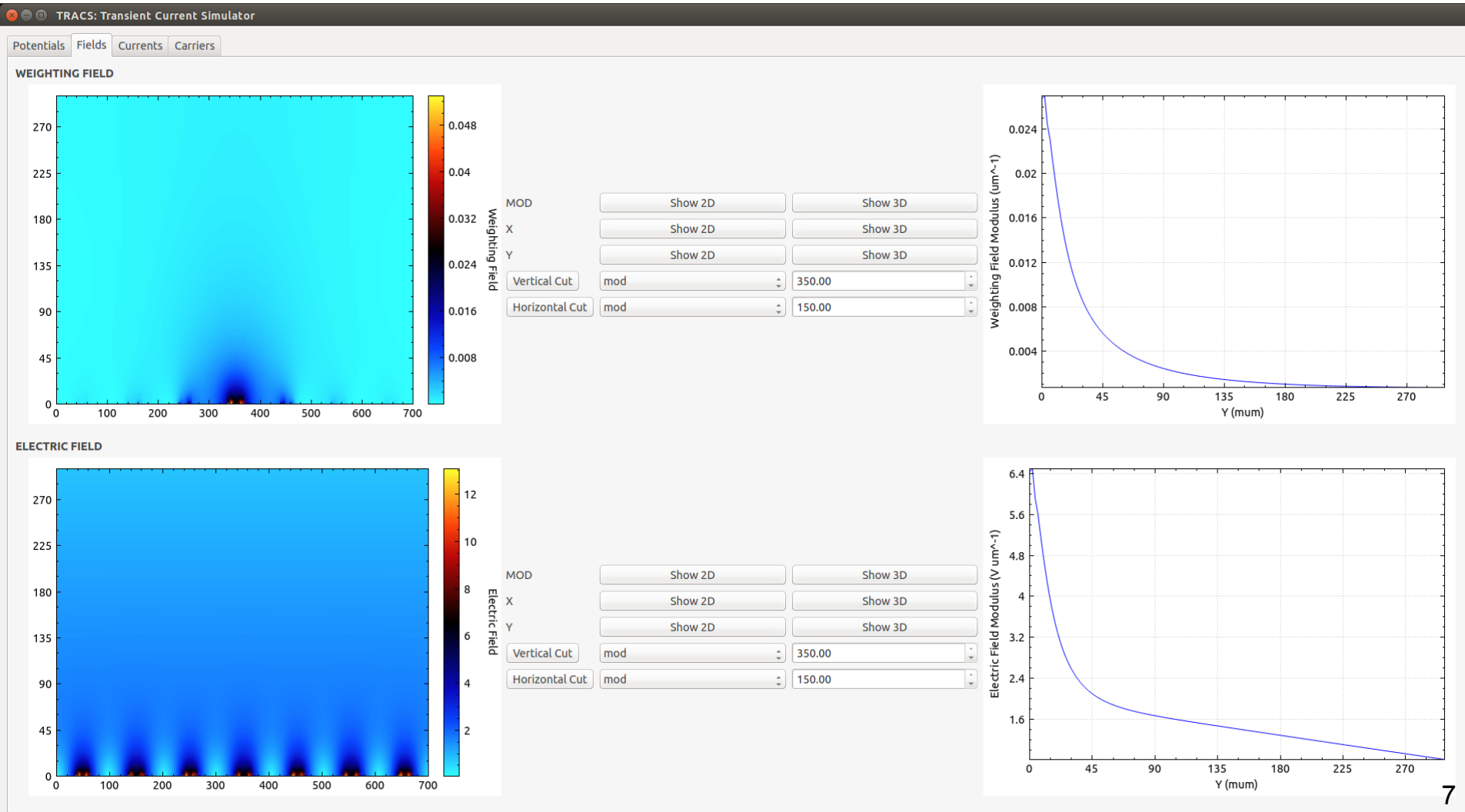
# What TRACS did

Simulate diode and strip detectors



# What TRACS did

Calculate weighting and electrical potentials and fields

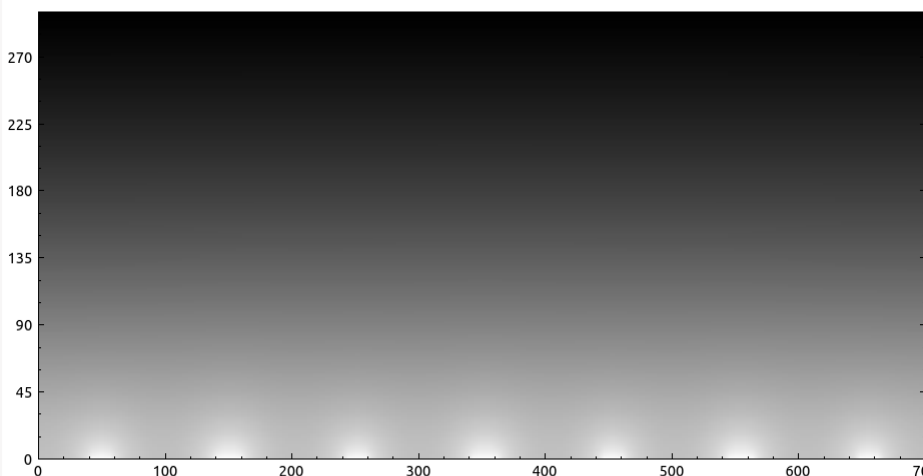


# What TRACS did

Simulate waveform due to a single e-h pair

TRACS: Transient Current Simulator

Potentials Fields Currents Carriers



270  
225  
180  
135  
90  
45  
0

0 100 200 300 400 500 600 700

7·10<sup>-10</sup>  
6·10<sup>-10</sup>  
5·10<sup>-10</sup>  
4·10<sup>-10</sup>  
3·10<sup>-10</sup>  
2·10<sup>-10</sup>  
1·10<sup>-10</sup>  
0

0 1.5·10<sup>-9</sup> 3·10<sup>-9</sup> 4.5·10<sup>-9</sup> 6·10<sup>-9</sup> 7.5·10<sup>-9</sup> 9·10<sup>-9</sup>

Current (A)

Time (s)

— electron  
— hole  
— total

**SINGLE CARRIER**

Carrier type: electron+hole

q (e units): 1

X Position (mum): 380.02

Y Position (mum): 173.24

Time Step (ps): 10.00

Max Time (ns): 10.00

# Steps: Generate and Drift

**CONSTANT CARRIER DISTRIBUTION THROUGH A LINE**

Start Point (x[mum], y[mum]): 0.00 0.00

End Point (x[mum], y[mum]): 0.00 0.00

Carrier Separation (mum): 0.00

View Line

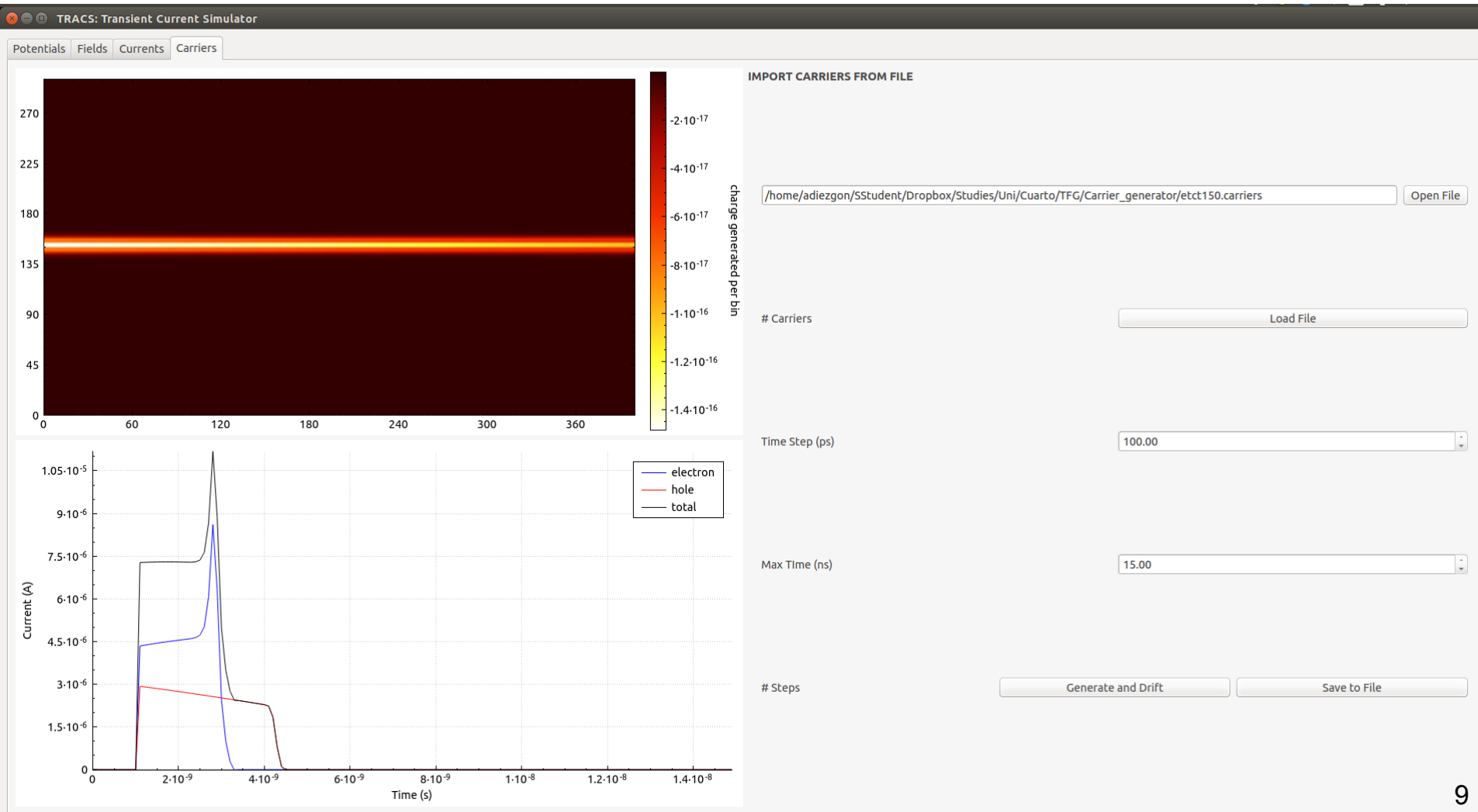
Generate and Drift

Save Results to File



# What TRACS did

Simulate signal generated by any kind of illumination  
simple RC shaping was also implemented in November



# First Step - Changing Neff distribution

Why is Neff important?

$$\nabla E = \frac{\rho}{\epsilon} \quad \nabla \phi = \vec{E}$$
$$\nabla^2 \phi = \frac{\rho}{\epsilon}$$

Integrate once



Get electric field

Integrate twice

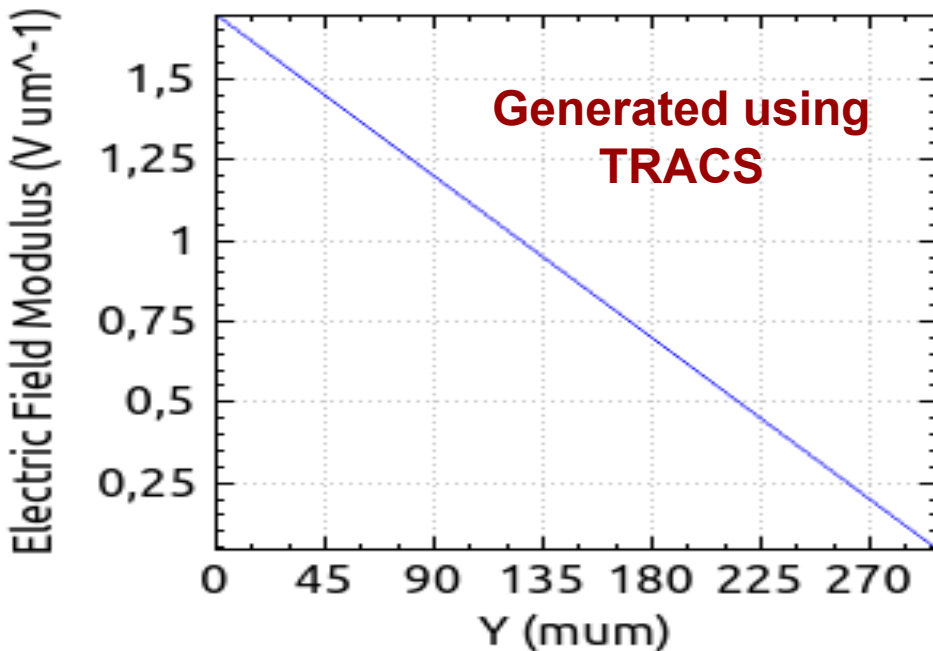
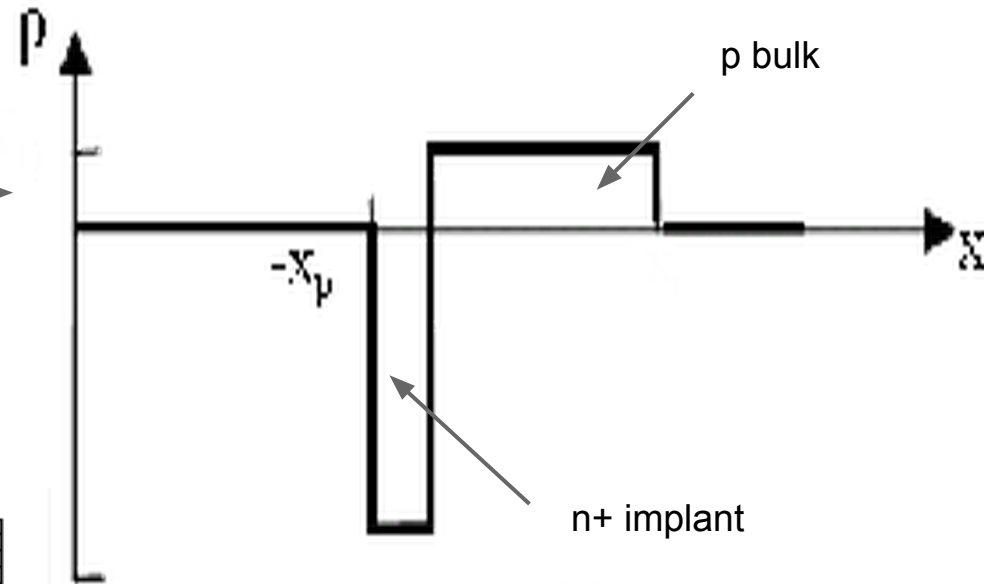


Get electric potential

# Neff before irradiation

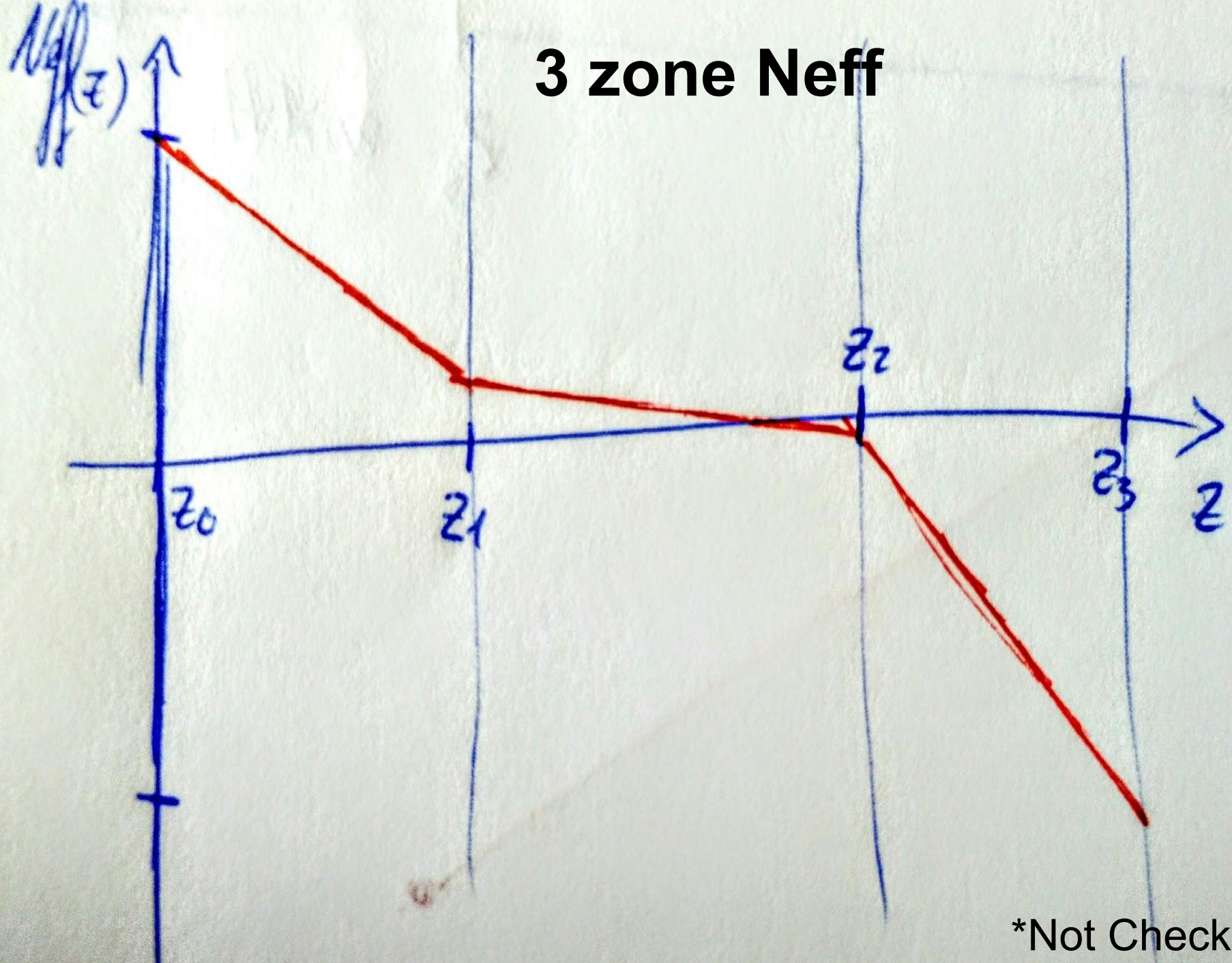
Constant space charge distribution

( $\rho$  in previous slide)



Linear Electric field

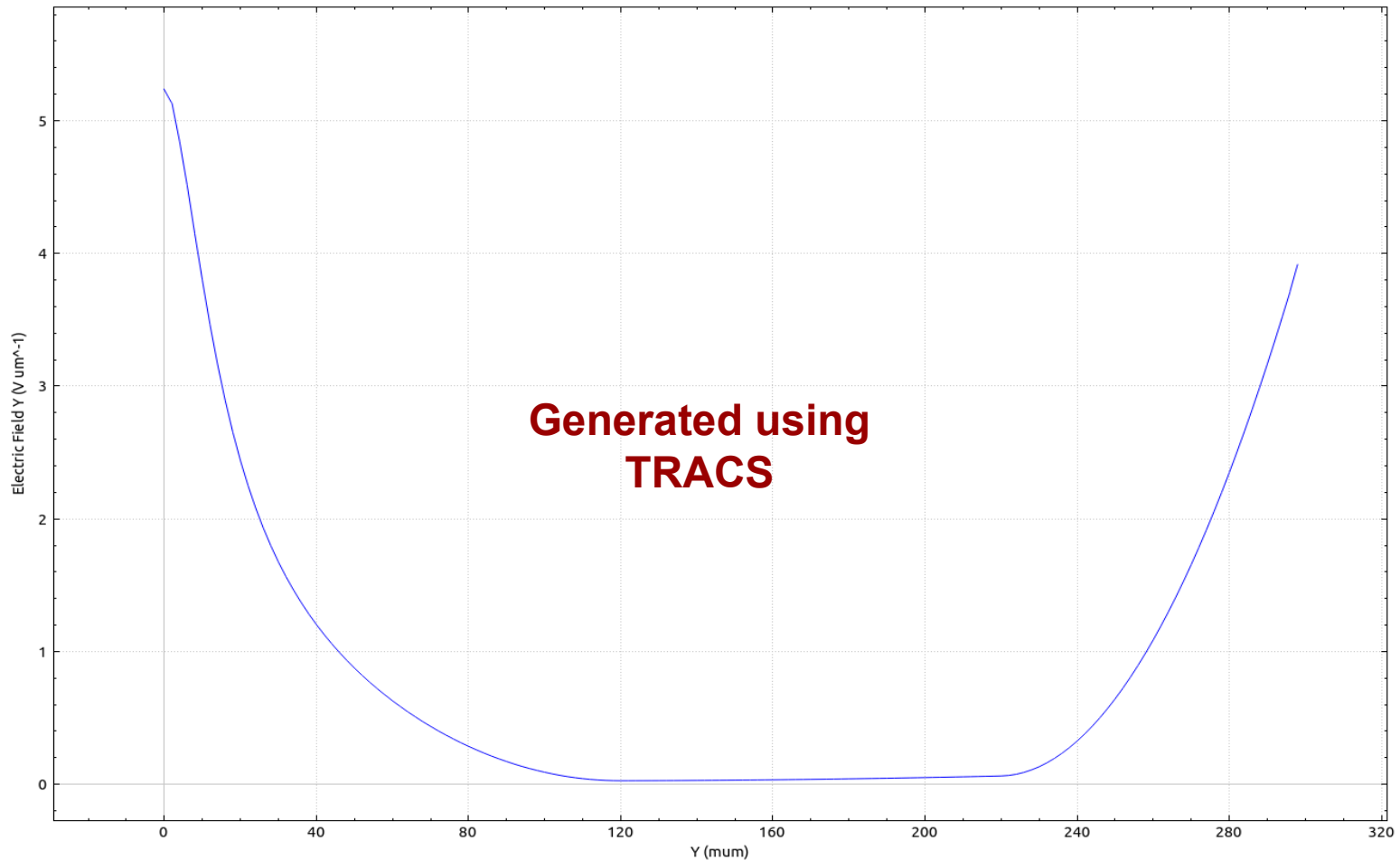
# 3 zone Neff



\*Not Checked

# Third Approach\* - 3 zone Neff

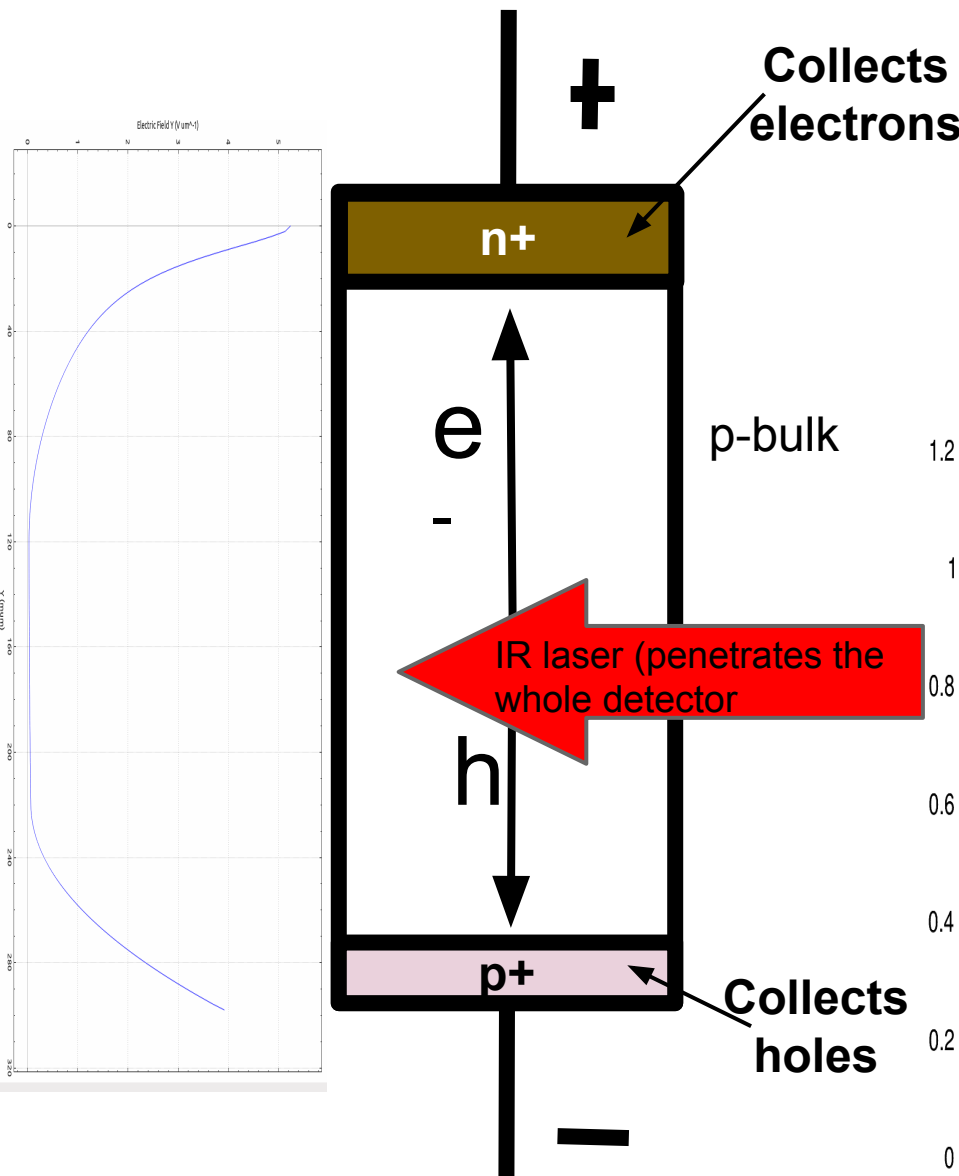
\*Not Checked



**3 parabolas (one per Neff zone)**

# Second Approach\* - 3 zone Neff

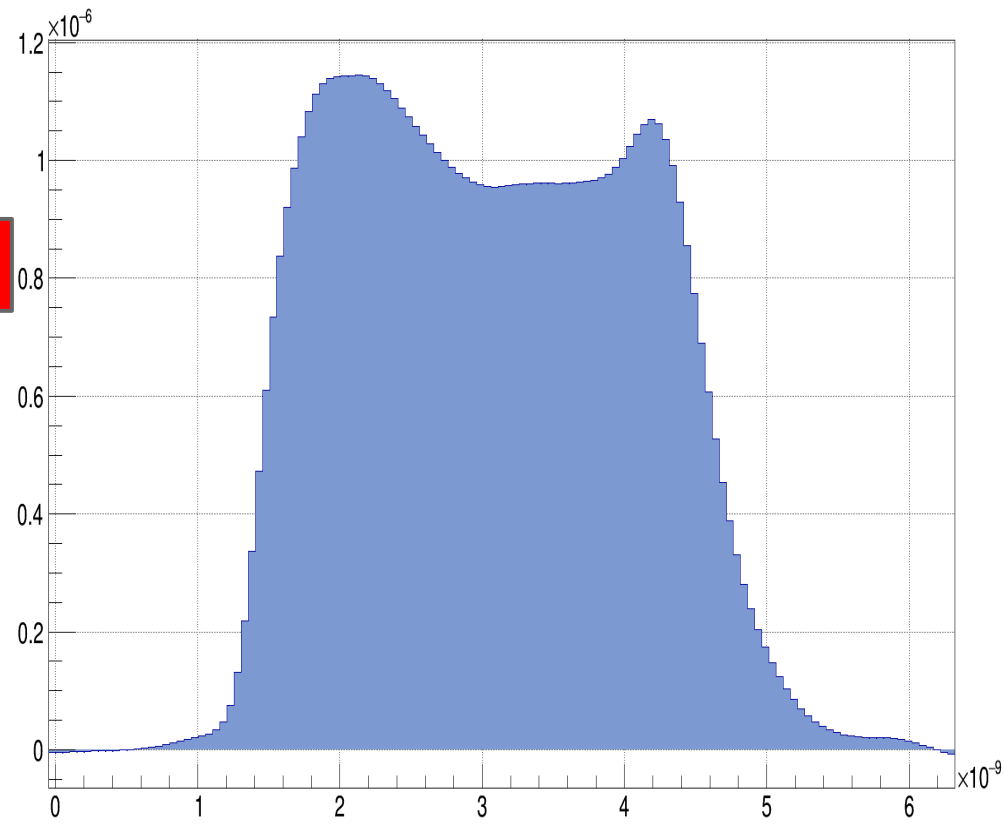
\*Not Checked



- Microstrip
- IR laser
- edge-TCT
- ~180 $\mu$ m

## Double peak

- Bias = 500v
- Vdep = 250v
- Irradiated



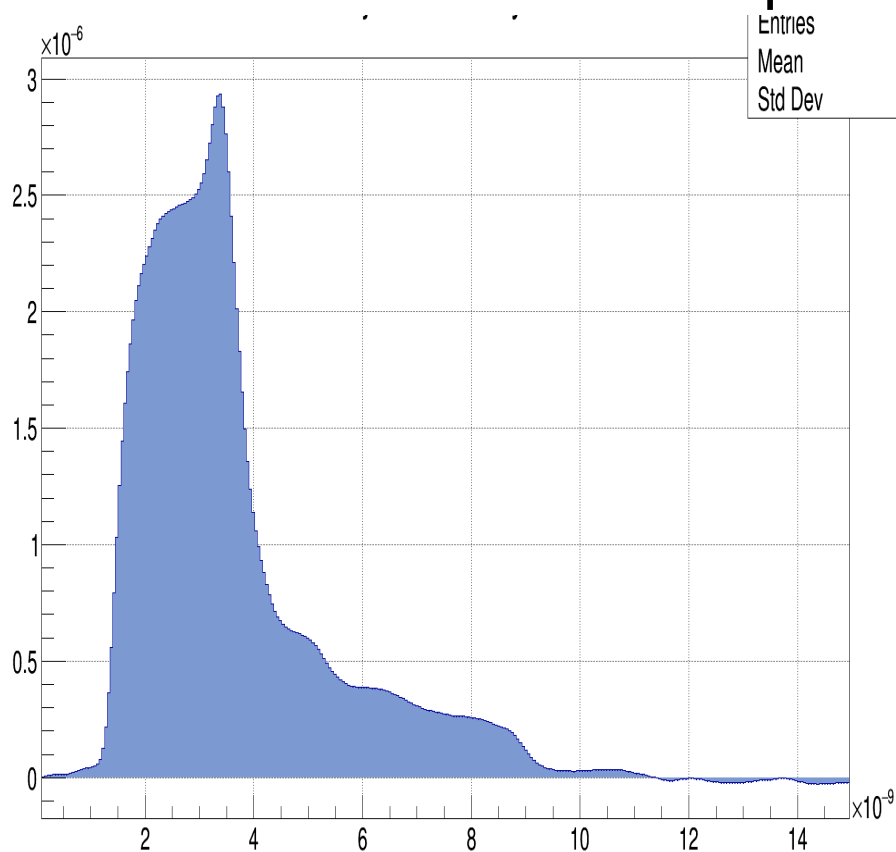
# NoIRRAD vs IRRAD

- Microstrip
- IR laser
- edge-TCT ( $\sim 180\mu\text{m}$ )

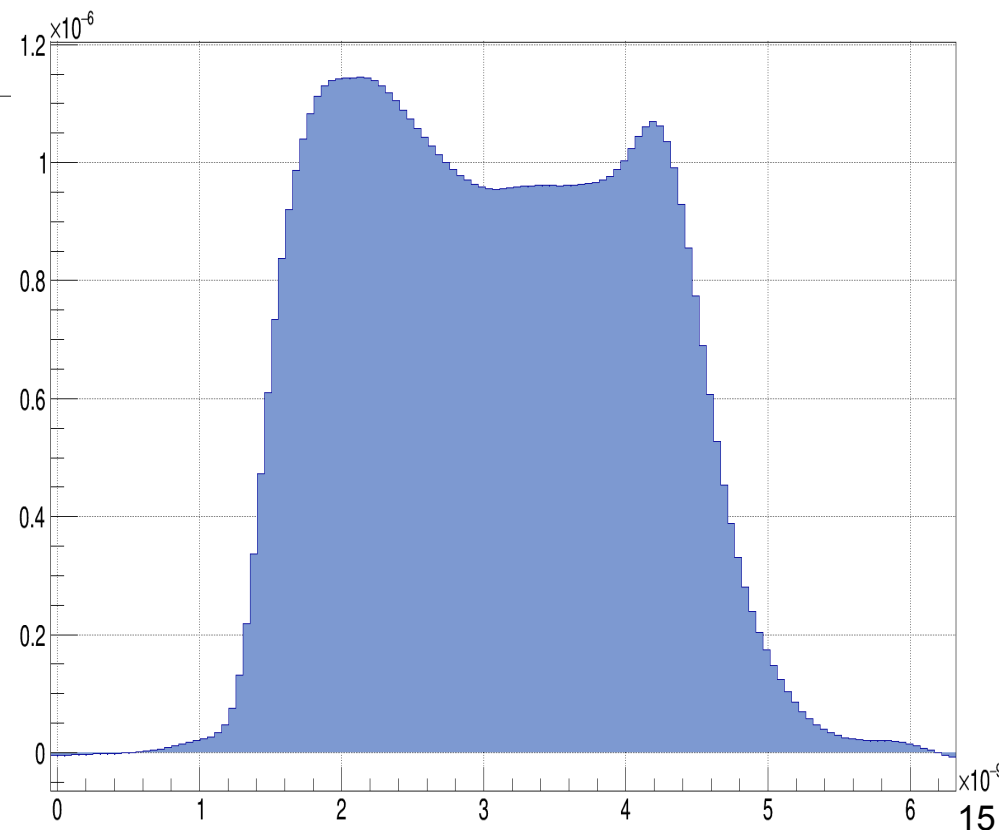
- Bias = 500v
- $V_{\text{dep}}^* = 250\text{v}$

\* $V_{\text{dep}}$  has no relevance for irradiated simulations

## Non-irradiated mirostrip



## Irradiated mirostrip



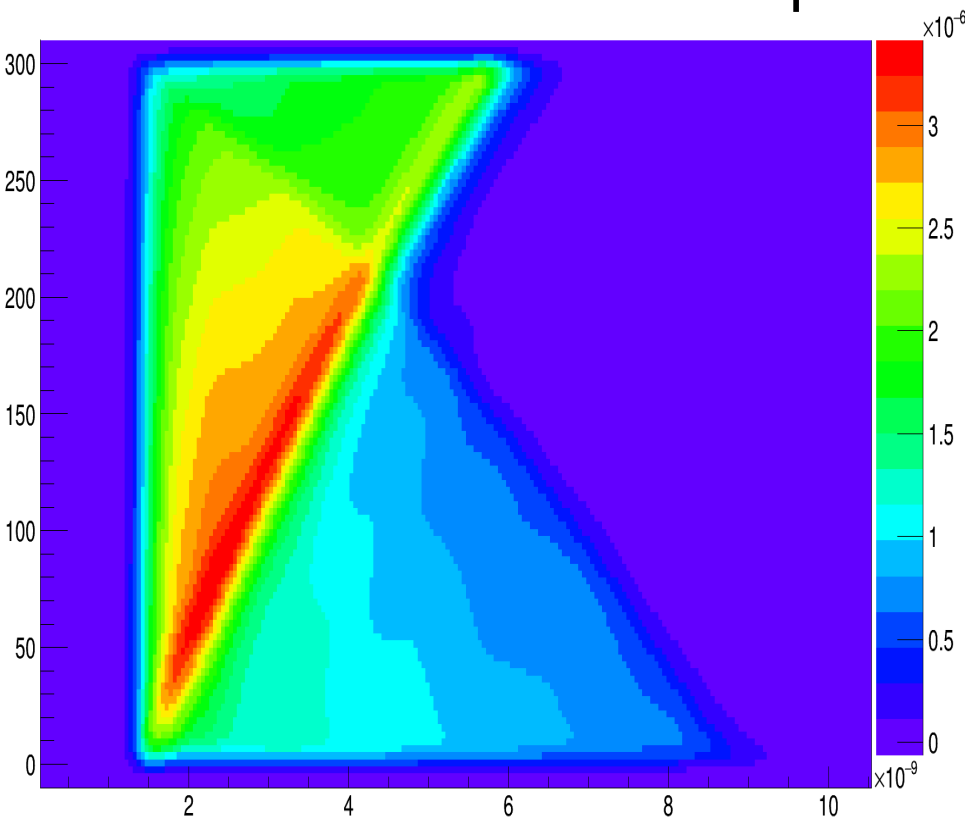
# NoIRRAD vs IRRAD

- Microstrip
- IR laser
- edge-TCT

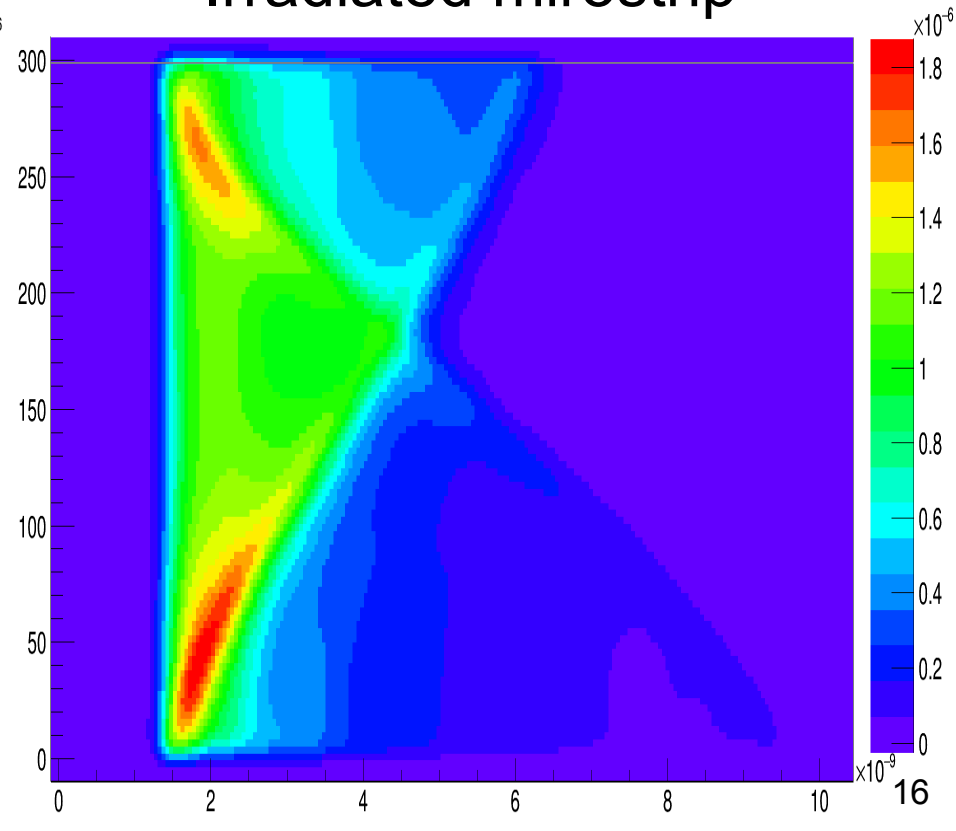
- Bias = 500v
- Vdep\* = 250v

\*Vdep has no relevance for irradiated simulations

## Non-irradiated mirostrip



## Irradiated mirostrip





# Progress report

## All that TRACS already does and ...

- Simulation of irradiated detectors (given Neff distribution)
- Include trapping effects
- Improve RC shaping by means of convolution with amplifier
- Output format mimicks TCT+ data format. Simulation can be analyzed with standard eTCT analysis software
- Improved performance using less carriers per simulation
- Further performance improvements through parallelization
- Fit simulation to experimental data
- ? Irradiated simulation in GUI
- ? Input file to avoid recompiling all the time

# Near future

Type of simulation	Before improvements	After Improvements	Expected with parallelization
edge-TCT/50ps 1-laser height	<b>~200s</b>	<b>~20s</b>	<b>3-10s</b>
edge-TCT/50ps/3um full detector	<b>~3h</b>	<b>~30min</b>	<b>4-15min</b>

## Simulation time



Trimmed version  
of \*.carriers file

Make “main.cpp” accept input parameters

## Fitting

Will call “main.cpp” with different  
Neff configurations searching for  
the best fit to measurements

Write minimization code  $\chi^2$

# One more thing...

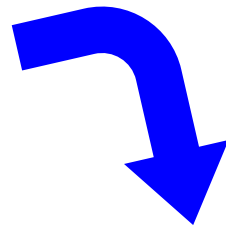
Code is available  
on GitHub



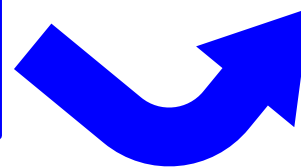
[github.com/IFCA-HEP/TRACS](https://github.com/IFCA-HEP/TRACS)

**You are  
encouraged to**

**Try**



**Report**



**Contribute**

**Thanks for  
your attention**

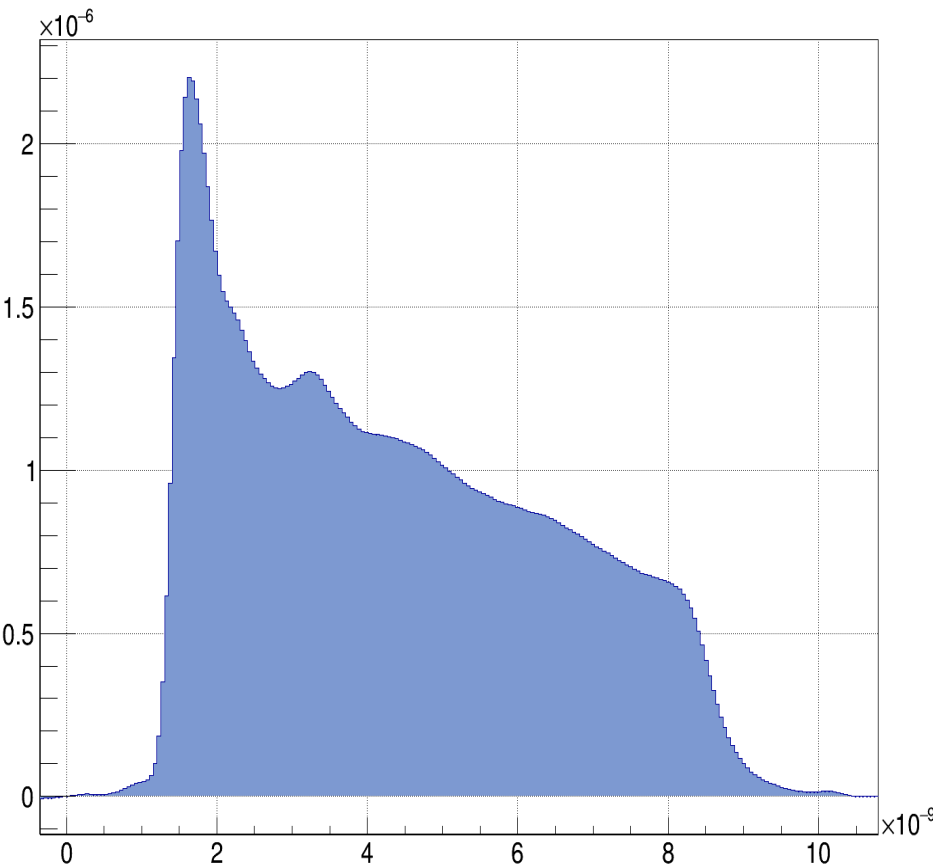
# NoIRRAD vs IRRAD

- Microstrip
- IR laser
- edge-TCT ( $\sim 15\mu\text{m}$ )

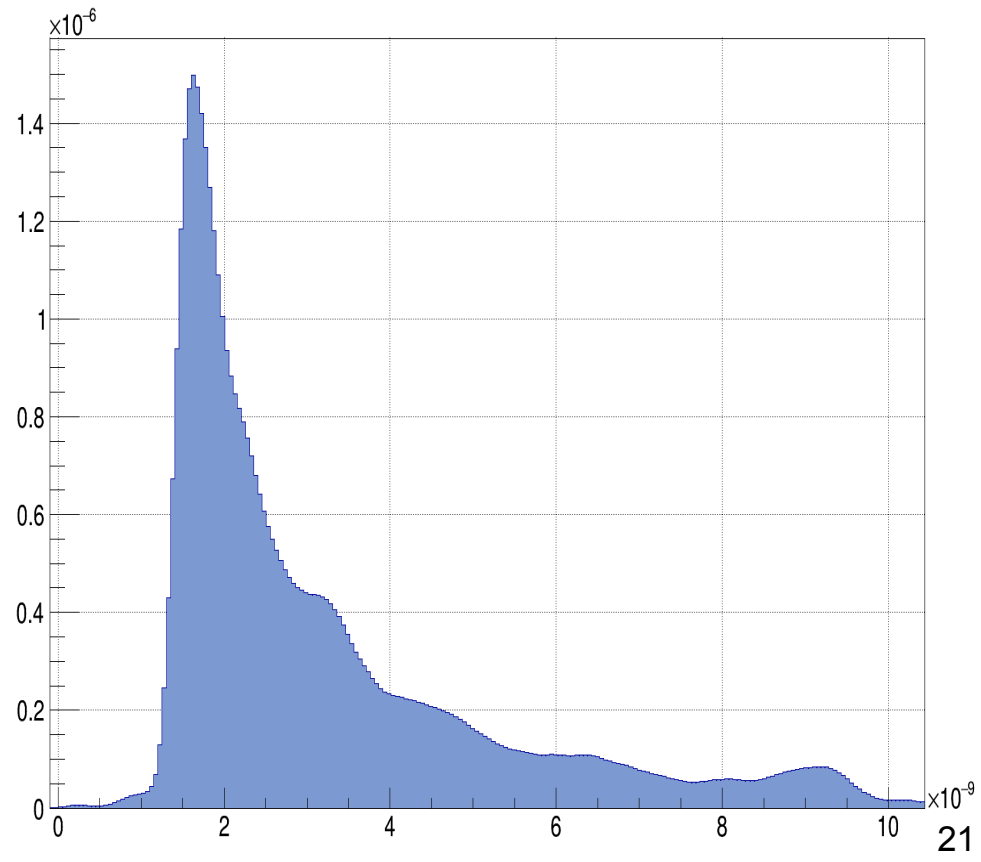
- Bias = 500v
- $V_{\text{dep}}^* = 250\text{v}$

\* $V_{\text{dep}}$  has no relevance for irradiated simulations

## Non-irradiated mirostrip



## Irradiated mirostrip



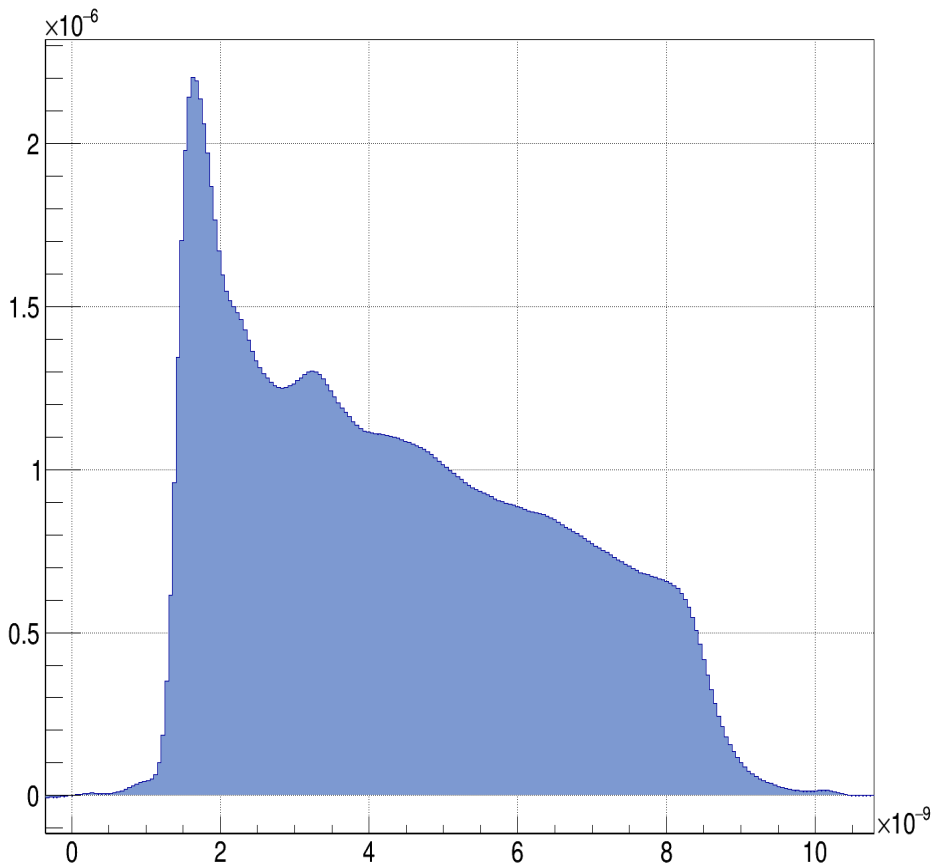
# NoIRRAD vs IRRAD

- Microstrip
- IR laser
- edge-TCT (~290 $\mu\text{m}$ )

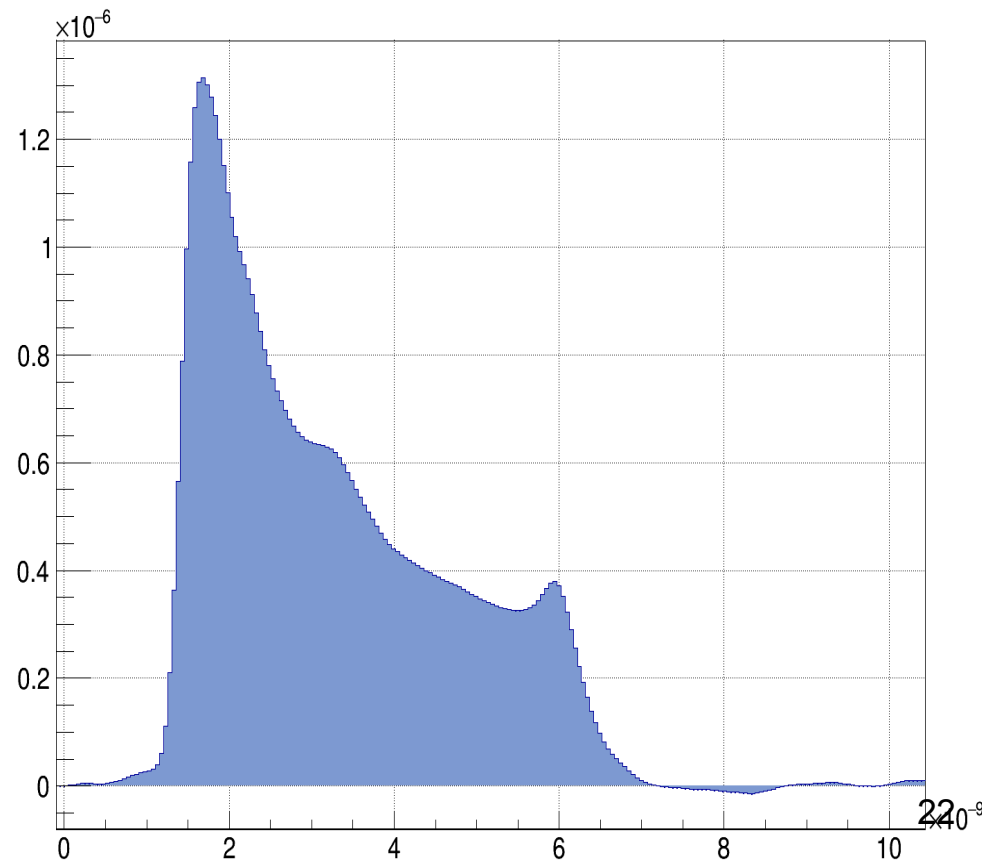
- Bias = 500v
- Vdep\* = 250v

\*Vdep has no relevance for irradiated simulations

## Non-irradiated mirostrip

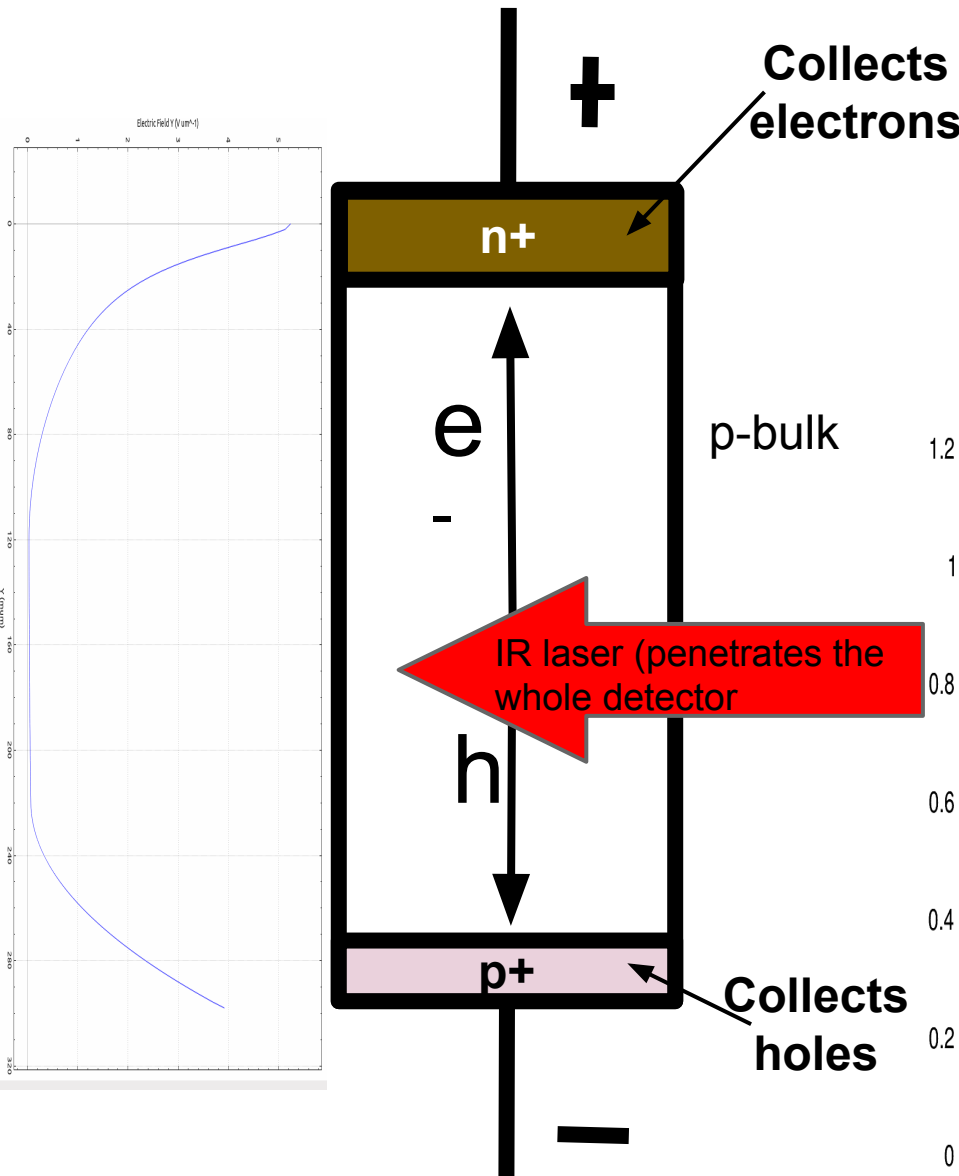


## Irradiated mirostrip



# Second Approach\* - 3 zone Neff

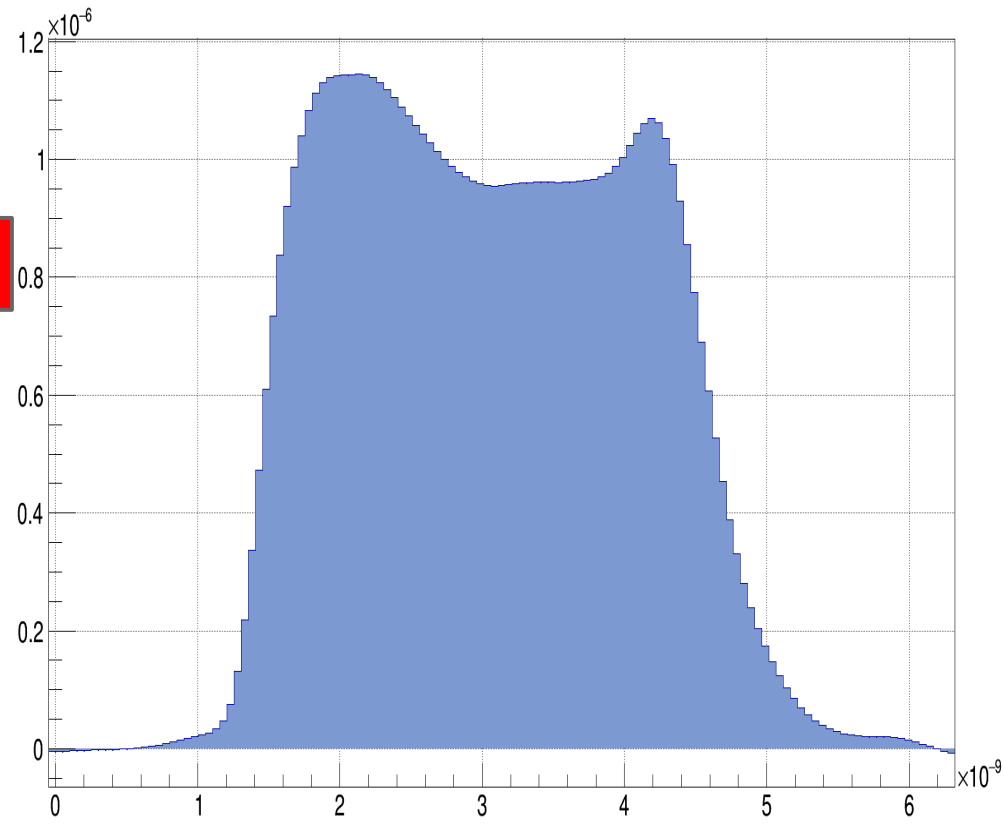
\*Not Checked



- Microstrip
- IR laser
- edge-TCT
- ~180 $\mu$ m

## Double peak

- Bias = 500v
- Vdep = 250v
- Irradiated



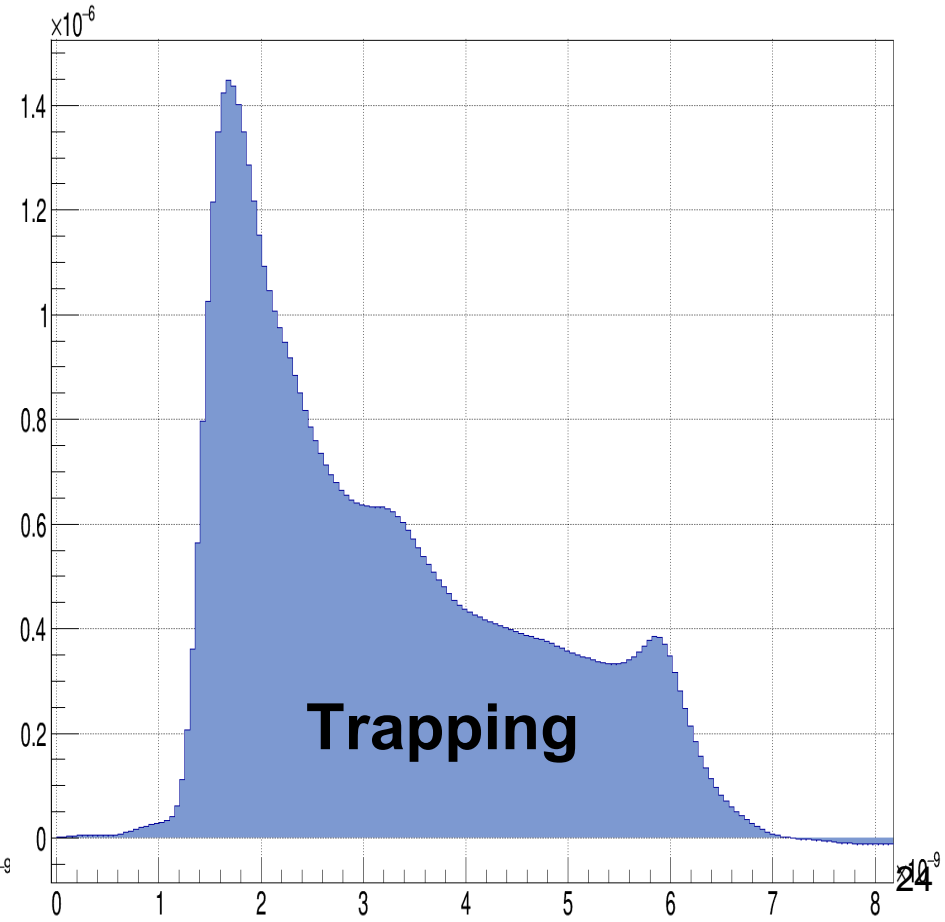
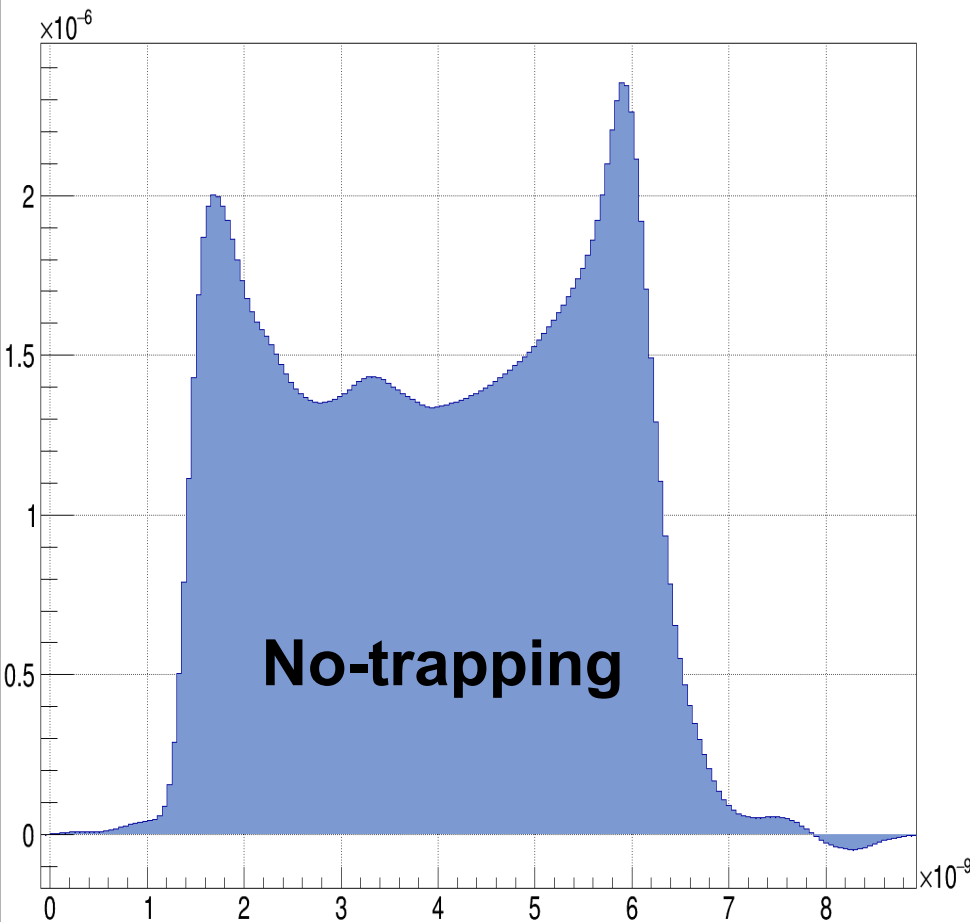
# Second Step - Trapping

Simple exponential decay - Fast and accurate enough

- Microstrip
- IR laser
- edge-TCT ( $\sim 280\mu\text{m}$ )

- Bias = 500v
- $V_{\text{dep}}^* = 250\text{v}$

\* $V_{\text{dep}}$  has no relevance for irradiated simulations





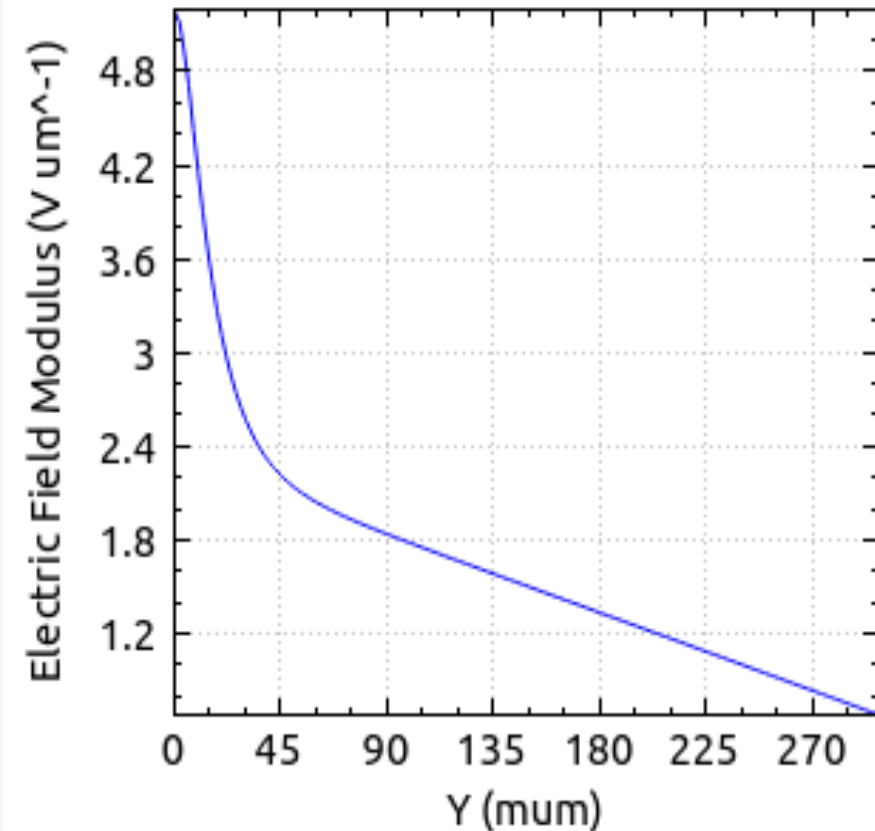
# NoIRRAD vs IRRAD

## FIELDS

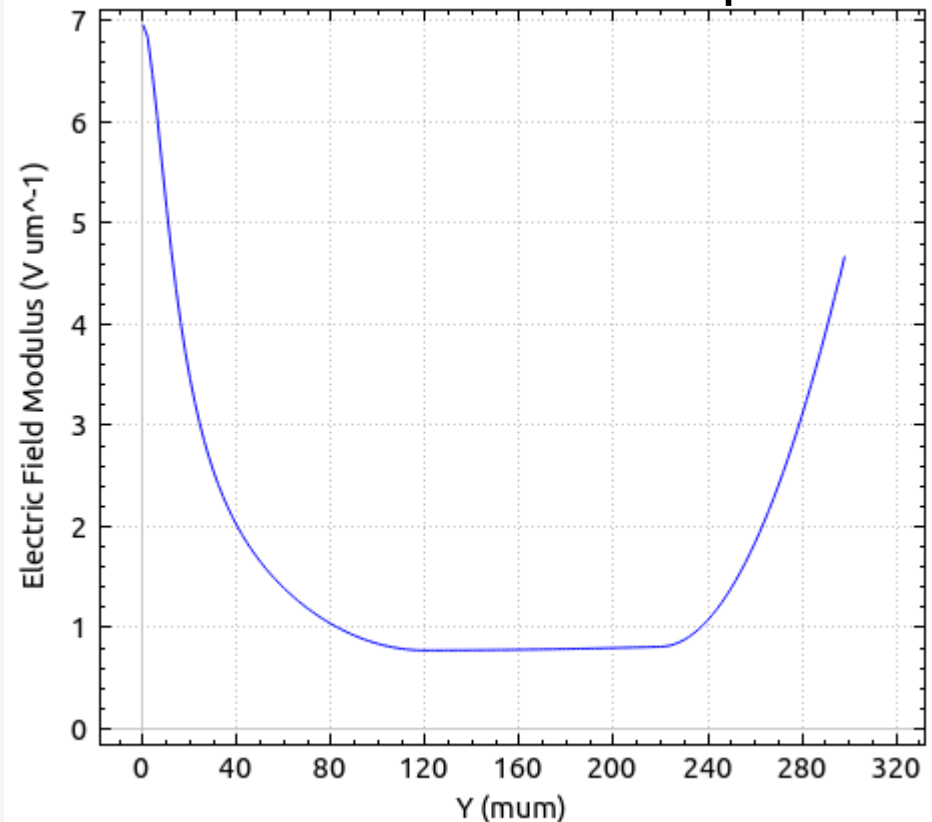
- Microstrip
- Bias = 500v
- $V_{dep}^* = 250v$

\* $V_{dep}$  has no relevance for irradiated simulations

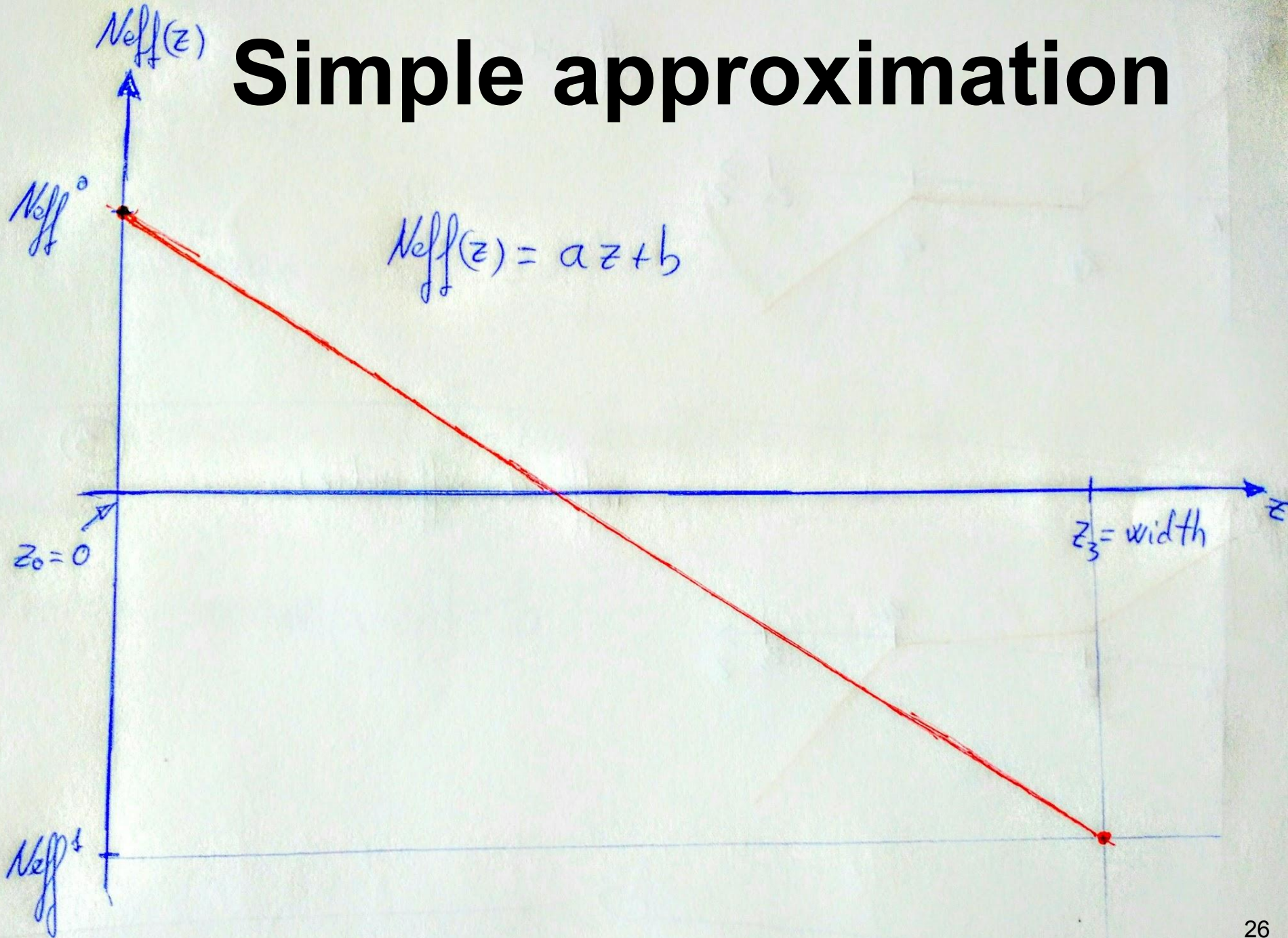
### Non-irradiated mirostrip



### Irradiated mirostrip



# Simple approximation



# Agreement with published results

